



PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.: **10/549,609**
Filing Date: September 20, 2005
Applicant: Tomoko AKAI et al.
Conf. No.: 8155
Group Art Unit: 1791
Examiner: Margaret Squalls
Title: METHOD FOR PRODUCING HIGH SILICATE GLASS AND
HIGH SILICATE GLASS (as amended)
Atty. Dkt. No.: 12480-000144/US

Customer Service Window
Randolph Building
401 Dulany Street
Alexandria, VA 22314
Mail Stop **AF**

October 21, 2010

RESPONSE UNDER 37 C.F.R. § 1.116

Dear Sir:

In response to the Final Office Action (hereinafter 'Action') mailed on July 22, 2010, the following remarks are respectfully submitted in connection with the above-identified patent application.

	Claims remaining after Amendment		Highest number previously paid for		Present extra
Total	18	-	20	=	0
Independent	1	-	3	=	0